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(12) **United States Design Patent**
Chang et al.

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(45) **Date of Patent:** ** **Sep. 17, 2013**

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(54) **ANALYSIS SYSTEM**

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(73) Assignee: **Cepheid**, Sunnyvale, CA (US)

(**) Term: **14 Years**

(21) Appl. No.: **29/412,457**

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(51) **LOC (9) Cl.** **24-01**

(52) **U.S. Cl.**
USPC **D24/216**

(58) **Field of Classification Search**
USPC D24/216, 217, 219, 223–226, 231, D24/232, 107, 169, 186; D10/81; 422/500, 422/547, 62–65, 67; 435/287.1, 287.3; 436/43, 436/45, 47
See application file for complete search history.

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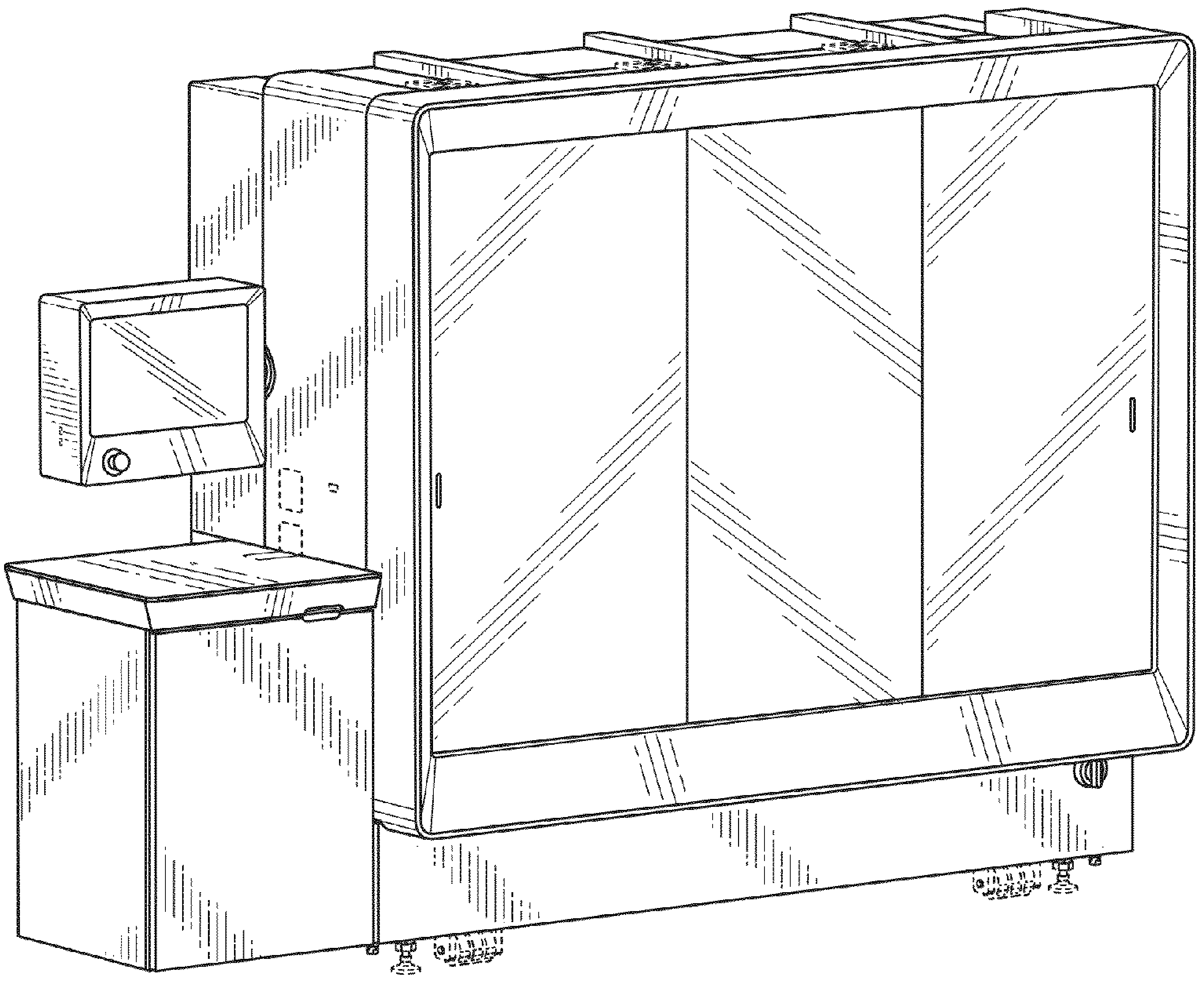
(57) **CLAIM**

The ornamental design for an analysis system, as shown and described.

DESCRIPTION

FIG. **1** is a perspective view of an analysis system showing our new design;
FIG. **2** is a front elevational view thereof;
FIG. **3** is a rear elevational view thereof;
FIG. **4** is a left side elevational view thereof;
FIG. **5** is a right side elevational view thereof;
FIG. **6** is a top plan view thereof; and,
FIG. **7** is a bottom plan view thereof.
The portions shown in broken lines form no part of the claimed design.

1 Claim, 5 Drawing Sheets



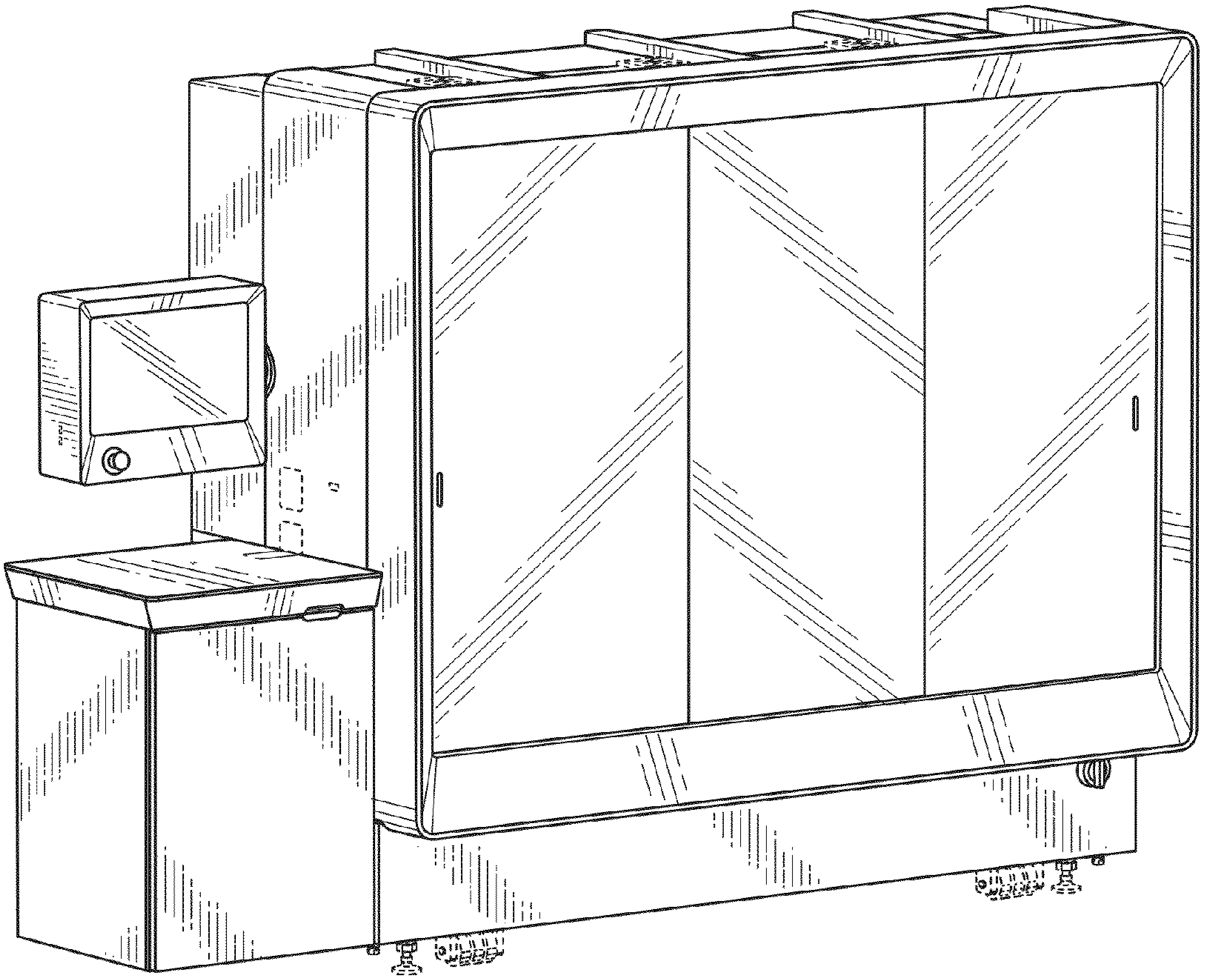


FIG. 1

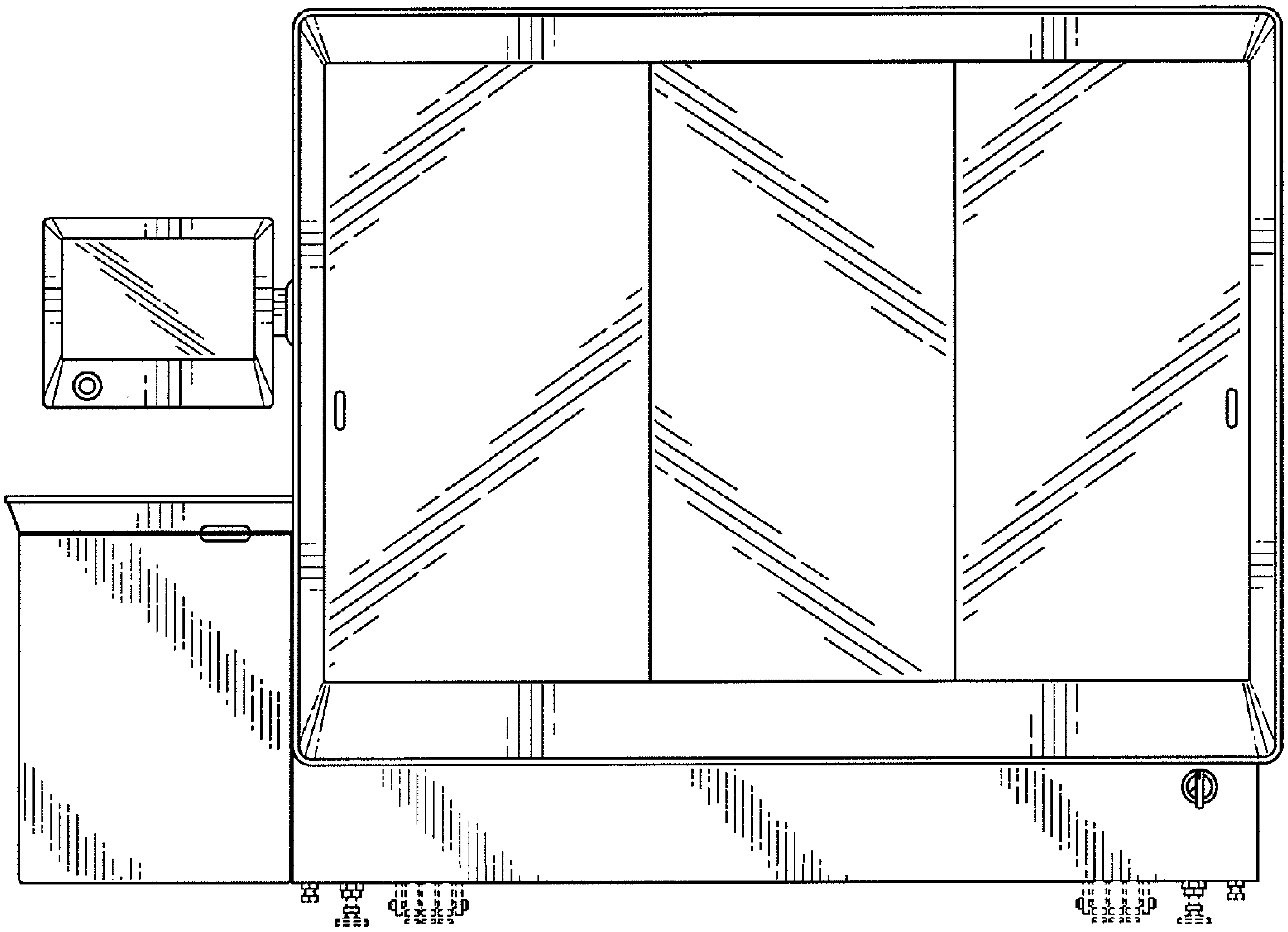


FIG. 2

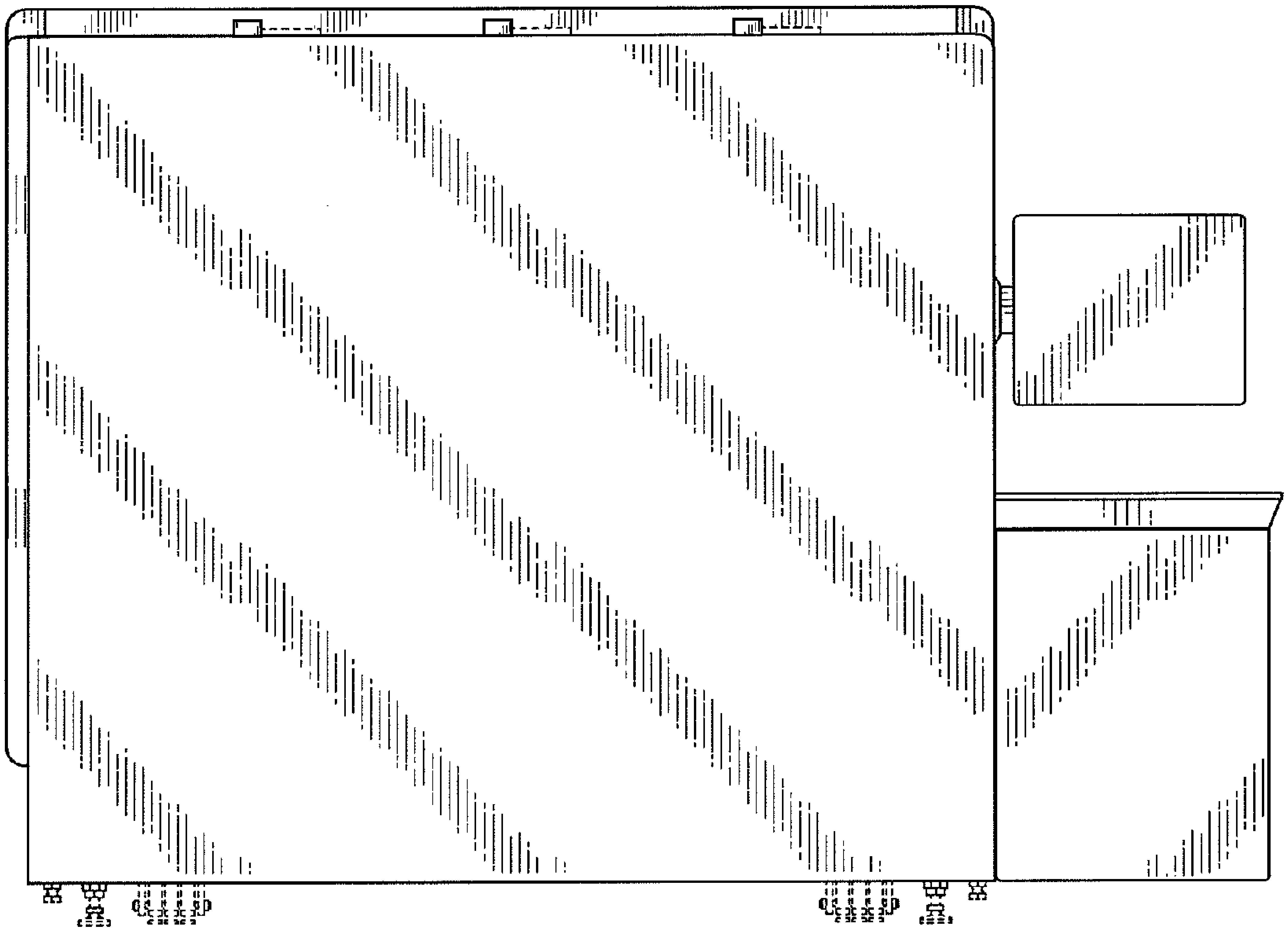


FIG. 3

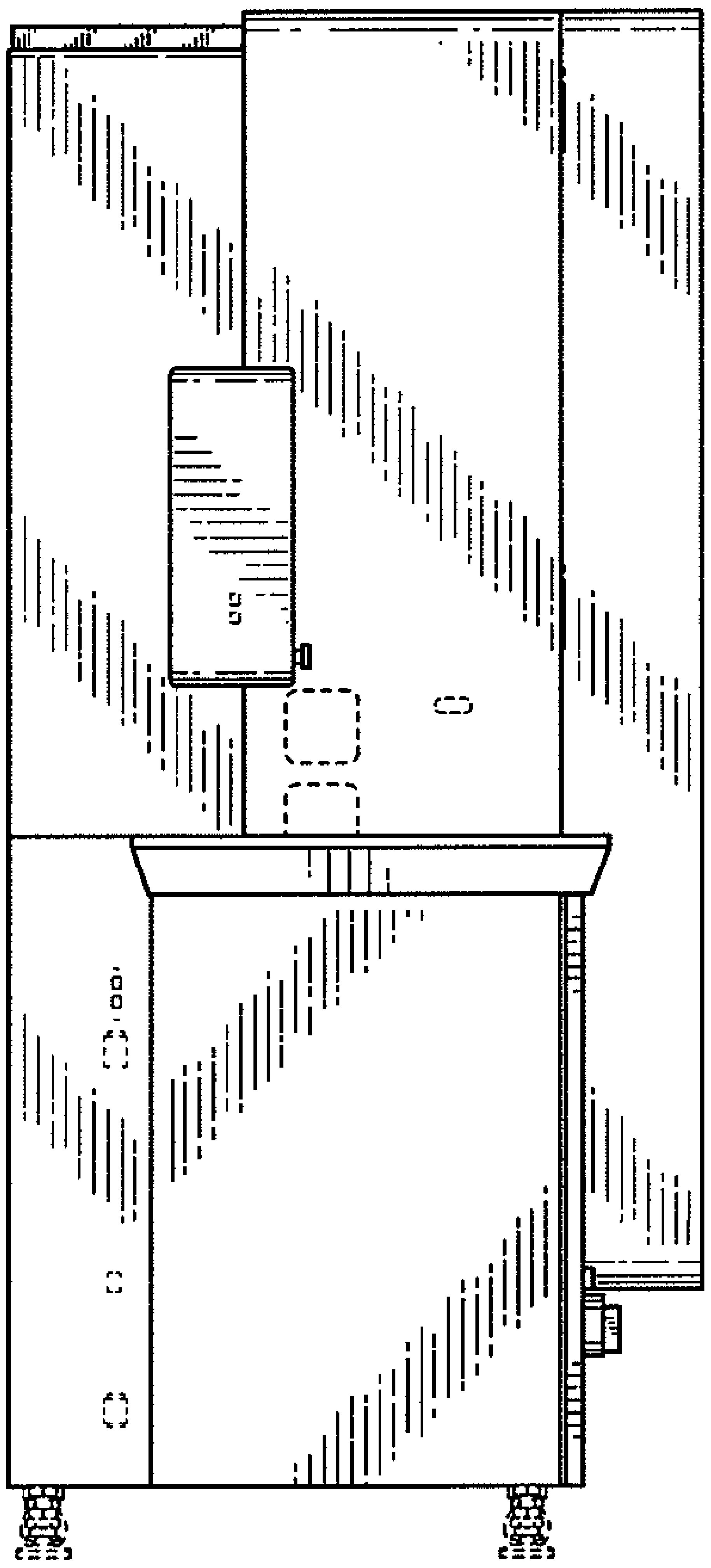


FIG. 4

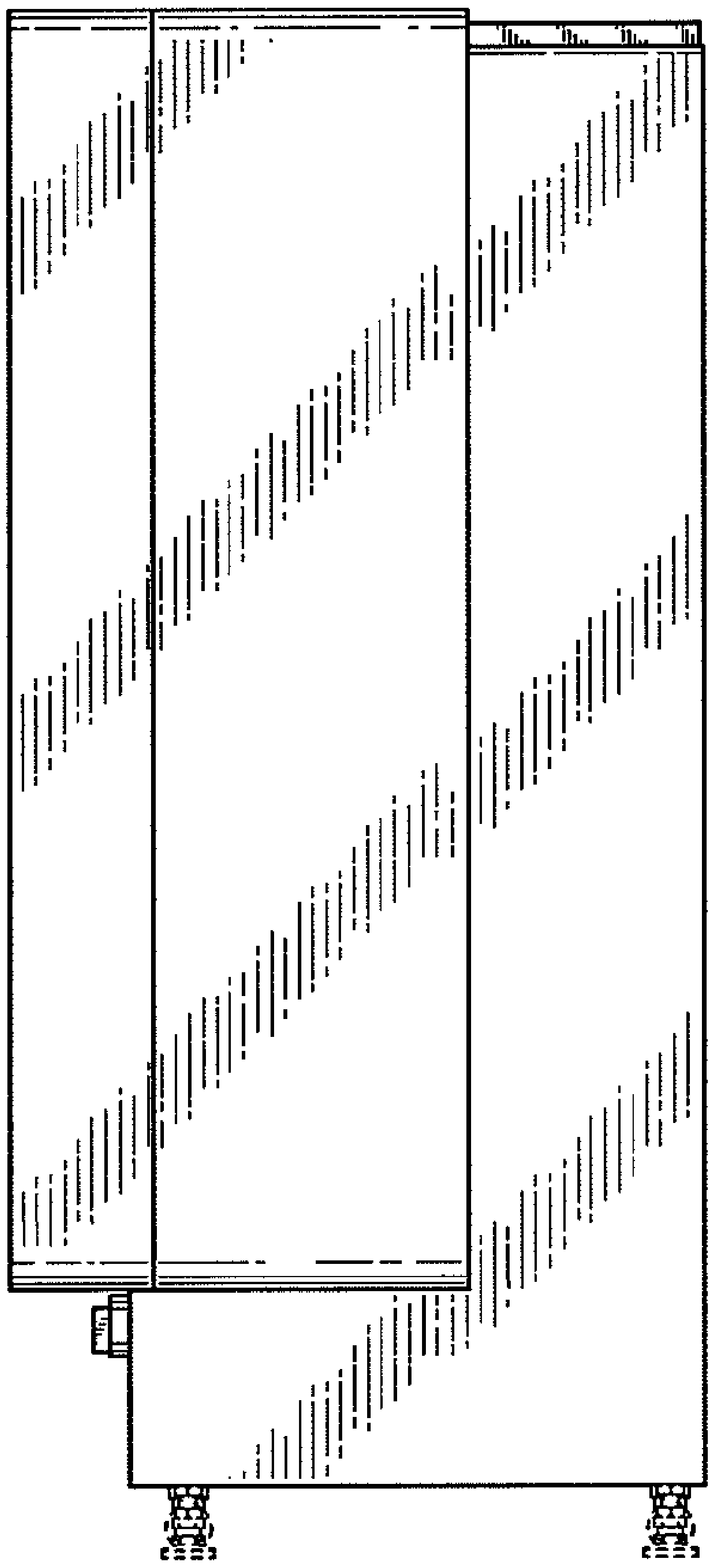


FIG. 5

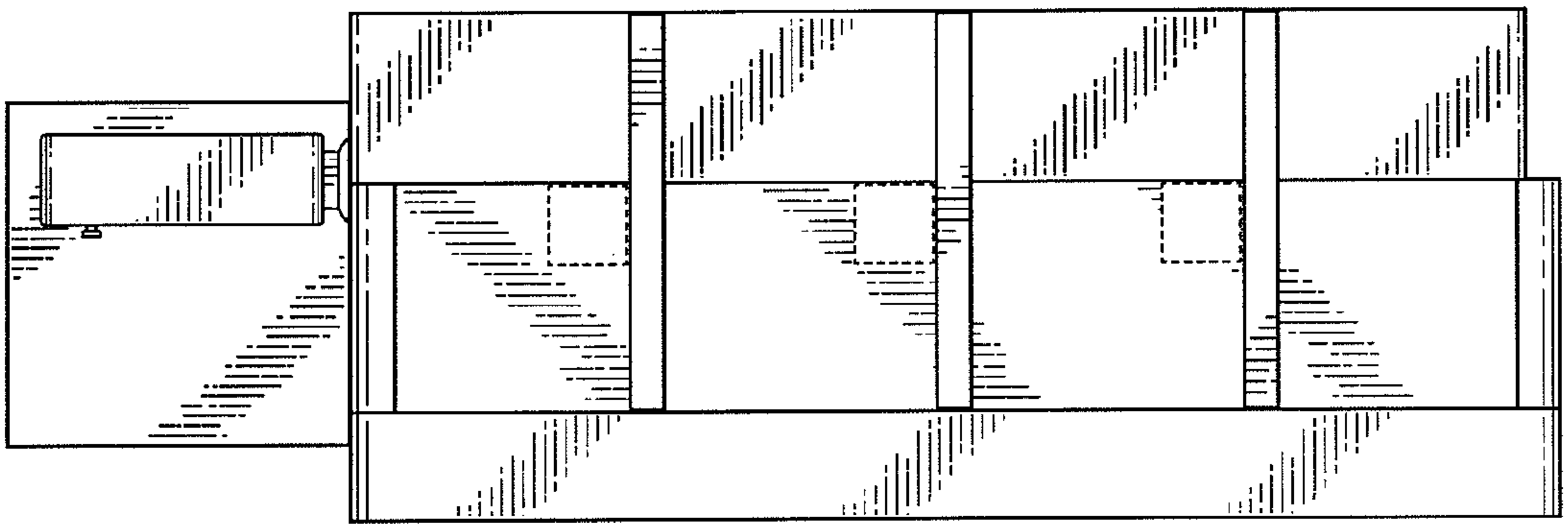


FIG. 6

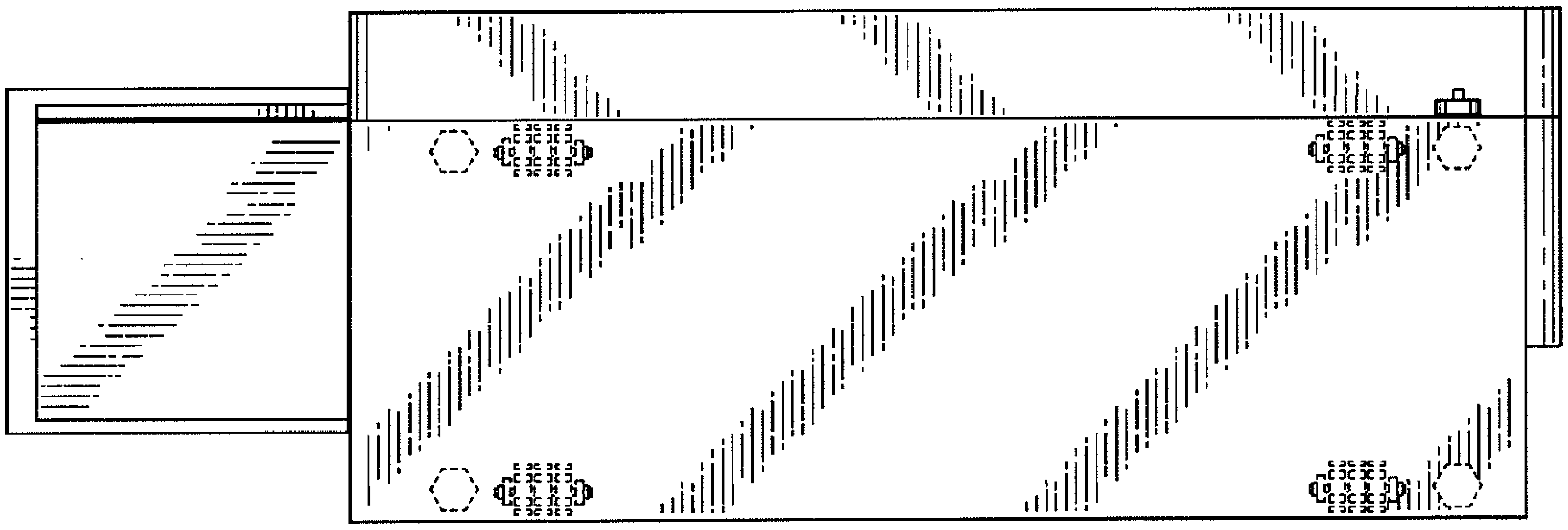


FIG. 7